ECE 3040 Microelectronic Circuits

Exam 1

September 27, 2023

Dr. W. Alan Doolittle

25 minuses

Print your name clearly and largely: Solution

Instructions:

DO NOT REMOVE ANY SHEETS FROM THIS EXAM! Read all the problems carefully and thoroughly before you begin working. You are allowed to use 1 sheet of notes (1 page front and back) as well as a calculator. There are 100 total points. Observe the point value of each problem and allocate your time accordingly. SHOW ALL WORK AND CIRCLE YOUR FINAL ANSWER WITH THE PROPER UNITS INDICATED. Write legibly. If I cannot read it, it will be considered a wrong answer. Do all work on the paper provided. Turn in all scratch paper, even if it did not lead to an answer. Turn in your notes sheet placed under your exam. Report any and all ethics violations to the instructor. A periodic table is supplied on the last page. Good luck!

Sign your name on **ONE** of the two following cases:

I DID NOT observe any ethical violations during this exam:

I observed an ethical violation during this exam:

First 20% Multiple Choice and True/False (Circle the letter of the most correct <u>answer or answers</u>)

- 1.) (2-points) True or False: The energy bandgap can be considered the energy required to rip an electron out of the material into the vacuum where it conducts electricity.
- 2.) (2-points) True or False: The mobility is the low electric field slope of the drift velocity, in the region where the drift velocity is linearly proportional to the electric field.
- 3.) (2-points) True of False) Electric fields are always applied from external sources like batteries and can never be created inside the device.
- 4.) (2-points) True of False: If both electrons and holes are exposed to a built in field, as in a solar cell, the charges both move to the same side of the device accumulating on the anode (p-side).
- 5.) (2-points) True or False: For a device with a high concentration of defect states or impurity states, the minority carrier lifetime will be very high.
- 6.) (2-points True r False: In a degenerately doped semiconductor, more than one hole can occupy a given state.
- 7.) (2-points) True or False: Larger bond strength results in higher energy bandgaps.
- 8.) (2-points) True or False: The Fermi-Dirac integral of order ½, the Fermi distribution function and the Boltzmann distribution function are all ways of describing the probability that a state is filled with an electron.
- 9.) (2-points) True or False: Auger recombination is only important at low current density or at low optical injection (low optical power).
- 10.)(2-points) True or False: Impact ionization can increase a small current into a large current but is generally noisy current as the multiplication of charge is random and thus, stochastic.

Short Answer ("Plug and Chug"):

11.)(6-points) Sketch and label the energy band diagram of <u>any</u> degenerately doped n-type semiconductor indicating why the material is degenerately doped and where the fermi-energy is. Points deducted for lack of neatness, clarity and missing energy labels. No numeric values are needed – just symbolic labels.

Ec-3KT ---- E;

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s-9 m) <u>glameter</u> a 300 nm long cylindrical semicon from position 12 is baned on two concessing states o

10 (Ward to + Marral)

and distribution

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For the following problems (12-13) use the following material parameters and <u>assuming total</u> <u>ionization</u>:

For InP:

 n_i =1.3e7 cm⁻³ N_D =3e13 cm⁻³ donors N_A =3e17 cm⁻³ acceptors

 $m_p^* = 0.6 m_o$ $m_n^* = 0.08 m_o$

 $E_G=1.344~eV$ Electron mobility, $\mu_n=900~cm^2/Vsec$ Hole mobility, $\mu_p=120~cm^2/V-sec$

Temperature=27 degrees C

12.)(7-points) Where is the fermi energy (relative to the valence band which is referenced to zero energy)? $E_{\lambda} = \frac{E_{3}}{2} + \frac{3}{2} \left(\frac{E_{7}}{2} \right) \ln \left(\frac{m_{p}^{2}}{m_{p}^{2}} \right)$

= 0,633eV

$$\rho = h'; e^{\frac{(energy)?}{(F_1' - E_P)/kT}}$$

$$E_{f} = \frac{3E_i - kT \ln \left(\frac{P}{h_i}\right)}{20.633 - kT \ln \left(\frac{3e17}{1e7}\right)}$$

$$= 0.633 - 0.618$$

$$E_{f} = 0.0145 eV$$

13.) (10-points) A 52 nm (1 nm = 1e-9 m) <u>diameter</u> x 300 nm long cylindrical semiconductor resistor is made from the semiconductor from problem 12 is biased on two opposing sides (longest dimension) with 0.9 volts. Determine <u>both</u> the electron and hole <u>currents</u> flowing in the device.

dimension) with 0.9 volts. Determine both the electron and hole currents flowing in the device.
$$900 \text{ cm}^2/v-5$$

$$A = \begin{bmatrix} 52 \text{ e} \text{ P} \end{bmatrix}^2 \pi = 2.12 \text{ e} - 11 \text{ cm}^2 \qquad V = 0.9$$

$$Po = NA \qquad (V_A 77 N_D + N_A 77 N_1) \qquad = 8.11 \text{ e} - 2.0 \text{ /}2 \text{ cm}$$

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$$Po = NA \qquad (1.3 \text{ e} 7) = 5.63 \text{ e} - 4 \text{ cm}^{-3} \qquad = 5.76 \text{ //}2 - \text{ cm}$$

$$Po = \frac{n_1^2}{p_0} = \frac{(1.3 \text{ e} 7)^2}{3 \text{ e} 17} = 5.63 \text{ e} - 4 \text{ cm}^{-3} \qquad = 5.76 \text{ //}2 - \text{ cm}$$

$$Po = \frac{L}{\sigma_0 A} = \frac{3 \text{ e} - 5 \text{ cm}}{(3.12 \text{ e} - 1)} \text{ c}$$

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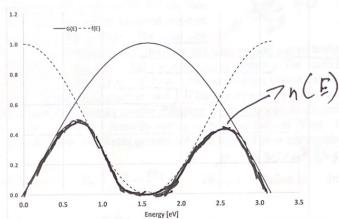
Section 3 (more short answer)

(13 -points total) The brilliant and humble Professor Doolittle has found a semiconductor that obeys new "Doolittian Physics". It is found the density of states of this material follows the function:

$$G(E) = \begin{cases} sin(E) \text{ for } 0 < E < \pi \\ 0 \text{ elsewhere} \end{cases}$$

and the fermi distribution function for this new physics is:

$$f(E) = \frac{1}{2} [1 + \cos(2E)] \text{ for } 0 < E < \pi$$

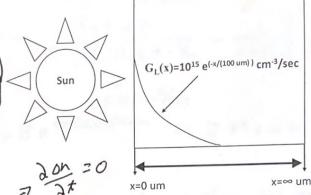


Sketch (do not label magnitudes) of the electron concentration versus energy function n(E) for $0 < E < \pi$.

Pulling all the concepts together for a useful purpose: 15.) (44-points)

A semi-infinite length section of semiconductor is to be used as a solar cell. The sun's light is absorbed such that the surface (x=0) excess minority carrier concentration, $\Delta n(x=0)$, always equals the surface generation rate times the minority carrier lifetime. The generation rate throughout the semiconductor is dependent on position as:

 $G_L(x)=G_{LO} e^{-\alpha x}=10^{15} e^{(-x/(100 \text{ um}))} \text{ cm}^{-3}/\text{sec}$ for all x and cannot be assumed constant nor only on the surface. The solar cell



has been exposed to the sun since the last time we had a presidential nominee that was competent for the office (a long time - but we will assume infinity). The semiconductor is doped p-type with an acceptor concentration of le17 cm⁻³, has an intrinsic concentration of le10 cm⁻³ and has a minority carrier lifetime of 40 microseconds. If the semiconductor is held at room temperature (27 degrees C), determine the minority carrier diffusion current density at all positions in the semiconductor $(0 \ge x)$ ≥ ∞ um). Assume a minority carrier mobility of 230 cm²/Vsec. I note that this problem "may" or

b) Given: $0 = D_n \frac{d^2 \Delta n_p}{dx^2} - \frac{\Delta n_p}{\tau_n} + G_L \dots$

...General Solution is: $\Delta n_p(x) = Ae^{-x/L_n} + Be^{+x/L_n} + G_L \tau_n$ ~ 154 um

c) Given: $0 = D_n \frac{d^2 \Delta n_p}{dx^2}$

General Solution is:
$$\Delta n_p(x) = A + Bx$$

d) Given: $0 = D_n \frac{d^2 \Delta n_p}{dx^2} + G_L$ General Solution is: $\Delta n_p(x) = Ax^2 + Bx + C$

e) Given: $0 = D_n \frac{d^2 \Delta n_p}{dx^2} + G_{LO} f(x) \dots$

... General Solution is:
$$\Delta n_p(x) = \left[-\frac{g_{LO}}{D_N} \iint f(x) dx^2 \right] + Bx + C$$

f) Given:
$$0 = D_n \frac{d^2 \Delta n_p}{dx^2} - \frac{\Delta n_p}{\tau_n} + G_{LO} e^{-\alpha x}$$
 ...

... General Solution is:
$$\Delta n_p(x) = Ae^{-x/L_n} + Be^{+x/L_n} - \frac{L_n G_{LO} e^{-\alpha x}}{2D_n} \left[\frac{1}{\left\{ \alpha - \left(\frac{1}{L_n} \right) \right\}} - \frac{1}{\left\{ \alpha + \left(\frac{1}{L_n} \right) \right\}} \right]$$

g) Given:
$$\frac{d\Delta n_p}{dt} = -\frac{\Delta n_p}{\tau_n}$$

h) Given: $0 = -\frac{\Delta n_p}{\tau_n} + G_L$

General Solution is:
$$\Delta n_p(t) = \Delta n_p(t=0)e^{-t/\tau_n}$$

h) Given:
$$0 = -\frac{\Delta n_p}{\tau_n} + G$$

General Solution is:
$$\Delta n_p = G_L \tau_n$$

 $\frac{100 \text{ cm}^{-1}}{\text{On}(x) = Ae^{-x/Ln}} + Be^{+x/Ln} - \frac{Ln GLo}{2 Dn} \left[\frac{1}{\alpha - \frac{1}{2} Ln} - \frac{1}{\alpha + \frac{1}{2} Ln}\right] e^{-\alpha x}$ = Ae-x/0.0154cm + Be+x/0.0154cm - 2.89e10e-100x B. C. : On (x-700)=> B=0 to avoid unphysical results Dn(x=0) = GL(x=0) cn = 4e10 = A - 2.89e10 A = 6.689 e10 cm-3 : On (x)= 6,689 e10 e -x/0.0154cm - 2,89 e10e-100x but Vno=0 so.,. J=q Dn V(an) Jn= q Dn Vnp(x) Jag In Han $\overline{J}_{n} = \left(1.6e19\right)\left(5.957\right)\left[-\frac{6.689e10}{0.0154}e^{-x/L_{n}} + (100)2.89e10e^{-100x}\right]$ Jn= [-4,26 MA/cm] e-x/0.0154cm + [202,76 MA/cm] e-100x Jn [MA/cm2] X